



Express Mail No. ER 843 147 155 US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: McElheny, et al.

Confirmation No.: 8609

Serial No.: 10/800,221

Art Unit: 2812

Filed: March 11, 2004

Examiner: Walter Lee Lindsay, Jr.

For: DUAL-OXIDE TRANSISTORS
FOR THE IMPROVEMENT OF
RELIABILITY AND OFF-
STATE LEAKAGE

Attorney Docket No: 060889-5002

FEE TRANSMITTAL SHEET

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The fee required to be filed with the accompanying amendment of even date herewith concerning the above-identified application has been estimated to be \$0.00.

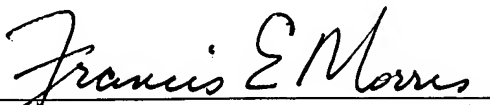
The claim amendment fee has been estimated as shown below:

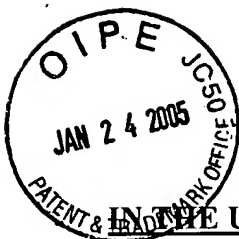
(Col. 1)0			(Col. 2)	(Col. 3)	<input type="checkbox"/> SMALL ENTITY		<input type="checkbox"/> OTHER THAN A SMALL ENTITY		
CLAIMS REMAINING AFTER AMENDMENT			HIGHEST NO. PREVIOUSLY PAID	PRESENT EXTRA	RATE	ADDIT. FEE	OR	RATE	ADDIT. FEE
TOTAL	11	MINUS	20		x 25	\$		x 50	\$ 0
INDEP.	3	MINUS	3		x 100	\$		x 200	\$ 0
						\$		\$	0.00
<input type="checkbox"/> FIRST PRESENTATION OF MULTIPLE DEP. CLAIM					TOTAL	\$	OR	TOTAL	\$ 0.00

Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310. A copy of this sheet is enclosed.

Respectfully submitted,

Date: January 24, 2005

 24,615
Francis E. Morris (Reg. No.)
Morgan, Lewis & Bockius LLP
101 Park Avenue
New York, NY 10178
(212) 309 6632
Customer No. 048591



01-26 05

IFW A

EXPRESS MAIL NO. ER 843 147 155 US

UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Peter John McElheny, et al. Confirmation No.: 8609
Serial No.: 10/800,221 Art Unit: 2812
Filed: March 11, 2004 Examine Walter Lee Lindsay, Jr.
For: DUAL-OXIDE r:
TRANSISTORS FOR THE Attorney Docket 060889-5002
IMPROVEMENT OF No.:
RELIABILITY AND OFF-
STATE LEAKAGE

AMENDMENT

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The enclosed Amendment is in response to the Office Action dated September 23, 2004 for the above identified patent application.